

CPC**COOPERATIVE PATENT CLASSIFICATION****C09G****POLISHING COMPOSITIONS OTHER THAN FRENCH POLISH; SKI WAXES****C09G 1/00****Polishing compositions** ([French polish C09F 11/00](#); [detergents C11D](#))**C09G 1/02**

- . containing abrasives or grinding agents {[abrasives as such C09K 3/14](#); [polishing of semi-conductors H01L](#) }

C09G 1/04

- . Aqueous dispersions ([C09G 1/02](#) takes precedence)

C09G 1/06

- . Other polishing compositions

C09G 1/08

- .. based on wax

C09G 1/10

- ... based on mixtures of wax and natural or synthetic resin

C09G 1/12

- mixtures of wax and silicon-containing polycondensates

C09G 1/14

- .. based on non-waxy substances

C09G 1/16

- ... on natural or synthetic resins

C09G 1/18

- ... on other substances

C09G 3/00**Ski waxes**